

	Hits	Search Text	DBs	Time Stamp
1	25	tetramethyl adj ammonium adj hydroxide same antireflective same substrate and photoresist	US - PGPUB; USPAT; EPO; JPO; DERWENT; IBM TDB	2006/06/05 12:35
2	2	ammonium adj fluoride same antireflective same substrate and photoresist	US - PGPUB; USPAT; EPO; JPO; DERWENT; IBM TDB	2006/06/05 12:41
3	6	ammonium adj fluoride same antireflective and substrate and photoresist	US - PGPUB; USPAT; EPO; JPO; DERWENT; IBM TDB	2006/06/05 12:41
4	2	(substrate and photoresist and (foot feet) and basic).clm.	US - PGPUB	2006/06/05 13:02
5	12	(substrate and photoresist and (foot feet)).clm.	US - PGPUB	2006/06/05 13:02
6	65	(substrate and photoresist and basic).clm.	US - PGPUB	2006/06/05 13:02
7	7	(substrate and photoresist with (foot feet)).clm.	US - PGPUB	2006/06/05 13:02
8	5	(substrate and photoresist and (treat treating treated) with basic).clm.	US - PGPUB	2006/06/05 13:03
9	1	(substrate and photoresist and substrate with (treat treating treated) with basic).clm.	US - PGPUB	2006/06/05 13:03
10	18	(substrate with (treat treating treated) with basic).clm.	US - PGPUB	2006/06/05 13:03
11	11	(substrate with (treat treating treated) with basic and ammonium).clm.	US - PGPUB	2006/06/05 13:03
12	0	(substrate with (treat treating treated) with basic and ammonium adj fluoride).clm.	US - PGPUB	2006/06/05 13:04
13	1	(substrate and (treat treating treated) with basic and ammonium adj fluoride).clm.	US - PGPUB	2006/06/05 13:04
14	2	(substrate with (treat treating treated) with basic and ammonium adj hydroxide).clm.	US - PGPUB	2006/06/05 13:04